

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	6522	216/27,37,41;438/689,700,702,719,723.ccls.	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:57
L2	10870	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L3	1874	(L2 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L4	75	L3 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L5	29	L4 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L6	25	L5 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L7	21	L6 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L8	21	L7 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L9	13	L8 and ((silicon adj oxide) or SiO)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
L10	4	L1 and L9	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:58
S1	10852	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 12:56
S2	1867	(S1 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:54
S3	73	S2 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:55
S4	29	S3 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:56
S5	25	S4 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:56
S6	9	S5 and (openin\$4 near5 pattern\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:11
S7	21	S5 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:58
S8	21	S7 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/29 12:58
S9	13	S8 and ((silicon adj oxide) or SiO)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:11
S10	2	S9 and (poly\$1etheramide)	US-PGPUB; USPAT	OR	OFF	2006/03/29 14:12
S11	0	S8 and ((silicon adj oxide) or SiO)	EPO; JPO; DERWENT	OR	OFF	2006/03/29 13:11

EAST Search History

S12	3	S9 and (polyether adj amide)	US-PGPUB; USPAT	OR	OFF	2006/03/29 14:17
S13	1	("6708398").PN.	US-PGPUB; USPAT	OR	OFF	2006/03/29 14:18
S14	5	((("5478606") or ("6126271") or ("6245245") or ("6390606") or ("6467884")).PN.	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:52
S15	10870	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S16	1874	(S15 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S17	75	S16 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S18	29	S17 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S19	25	S18 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S20	21	S19 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S21	21	S20 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:51
S22	0	S14 and S21	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:52
S23	0	S14 and S20	US-PGPUB; USPAT	OR	OFF	2006/03/30 07:52